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# INFORMATION DISCLOSURE STATEMENT

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Inventor:	Kent Erik MATTSSON
Art Unit:	Unassigned
Examiner:	Unassigned

## U.S. PATENT DOCUMENTS

Examiner Initials*	Cite No.	Document Number	Publication Date	Name of Patentee or Applicant	Relevant Pages, Cols, Lines, Figs.
/MJS/	AA	US-6,408,125 B1	06/18/02	Akwani et al.	
	AB	US-2002/0154878 A1	10/24/02	Akwani et al.	
	AC	US-2002/0182342 A1	12/05/02	Ouellet et al.	
	AD	US-2002/0194876 A1	12/26/02	Bona et al.	
	AE	US-2002/0178760 A1	12/05/02	Bona et al.	
	AF	US-2003/0021578 A1	01/30/03	Zhong et al.	
	AG	US-2003/0070451 A1	04/17/03	Ouellet et al.	
	AH	US-6,716,476 B2	04/06/04	Ouellet et al.	
	AI	US-6,887,514 B2	05/03/05	Ouellet et al.	

## FOREIGN PATENT DOCUMENTS

Examiner Initials*	Cite No.	Country Code + Number	Publication Date	Name of Patentee or Applicant	Relevant Pages, Cols, Lines, Figs.	Translation
/MJS/	AJ	WO 99/44937 A1	09/10/99	IBM Corp.		
	AK	WO 01/64594 A1	09/07/01	IBM Corp.		
	AL	WO 02/35265 A2	05/02/02	Corning Inc.		
	AM	JP 2000091079 A	03/31/00	TDK Corp.		Abstract
	AN	JP 11109158 A	04/23/99	Hitachi Cable Ltd.		Abstract
	AO	JP 09080247 A	03/28/97	Hitachi Cable Ltd.		Abstract
	AP	EP 1 295 963 A2	03/26/03	Dalsa Semiconductor Inc.		Equivalent
	AQ	EP 1 273 677 A2	01/08/03	Zarlink Semiconductor Inc.		Equivalent
	AR	EP 1 302 792 A2	04/16/03	Dalsa Semiconductor Inc.		Equivalent

## NON-PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No.	Include name of author in CAPS; title of article; title of book, magazine, journal etc.; date; page(s); volume/issue number(s); publisher; city and/country where published.
/MJS/	AS	Chelnokov, A.V., et al., "Deep high-dose erbium implantation of low-loss silicon oxynitride waveguides", Electronic Letters, Vol. 30, No. 22, October 27, 1994, pp. 1850-1852
	AT	Germann, R., et al., "Silicon oxynitride layers for optical waveguide applications", Journal of Electrochemical Society, Vol. 147, No. 6, June 2000, pp. 2237-2241 (XP009016715)
	AU	Albers, H., et al., "Reduction of hydrogen induced losses in PECVD-SiO <sub>x</sub> N <sub>y</sub> optical waveguides in the near infrared", IEEE Lasers and Electro-Optics Society 1995 Annual Meeting, 8 <sup>th</sup> Annual Meeting

Examiner Signature	/M. Stahl/	Date Considered	07/01/2007
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

(no month)